

## Editorial changes in 2010

On behalf of all the Editors and Elsevier I am delighted to welcome a new Associate Editor and several new Editorial Board members to *Surface Science*. Each person is an inspirational and leading researcher and we are excited to have them on board. Together with their areas of expertise they are:

### Associate Editor

David Castner

*Biosurfaces, biomaterials, polymer surfaces, surface analysis*

### Editorial Board Members

Jesper Andersen

*photoemission, surface structure, catalysis, chemisorption, oxide films*

Ludwig Bartels

*scanning tunneling microscopy (STM), self-assembled monolayers, tailoring molecular layers, adsorbate motion/dynamics*

Mischa Bonn

*ultrafast dynamics, non-linear spectroscopies, water interfaces, biological membranes*

Ib Chorkendorff

*catalysis, fuel cells, bimetallic surfaces*

Yves Chabal

*semiconductor surfaces, surface functionalization, micro- and nano-electronic interfaces, thin dielectric films, infrared spectroscopy*

Ulrike Diebold

*oxide surfaces, metal/oxide interfaces, STM*

Gaetano Granozzi

*theory, DFT, chemisorption, oxide surfaces, catalysis*

Angelos Michaelides

*theory, DFT, kinetics, quantum dynamics, water interfaces, catalysis*

Robert Wolkow

*molecular electronics, nanoscale contacts, STM, theory, semiconductor surfaces*

Francesco Zaera

*catalysis, chemisorption*

At the same time, I would like extend thanks to those people who retired from the journal at the end of 2009 at the end of their terms. We are grateful for their dedication and support to the Editors and the journal over their term of appointment.

### Associate Editor

Eric Stuve (USA)

### Editorial Board

Kristen Fichthorn (USA)

John Hemminger (USA)

Michael Horn-von-Hoegen (Germany)

Hannes Jonsson (USA and Iceland)

Neville Richardson (UK)

Miquel Salmeron (USA)

Catherine Stampfl (Australia)

Daniel Wayner (Canada)

Sincerely,

Charles T. Campbell

Editor in Chief